

Submillimeter-scale atomic-thin metallic MoO₂ with noble metal-comparable SERS performance realized by thickness-dependent enhancement

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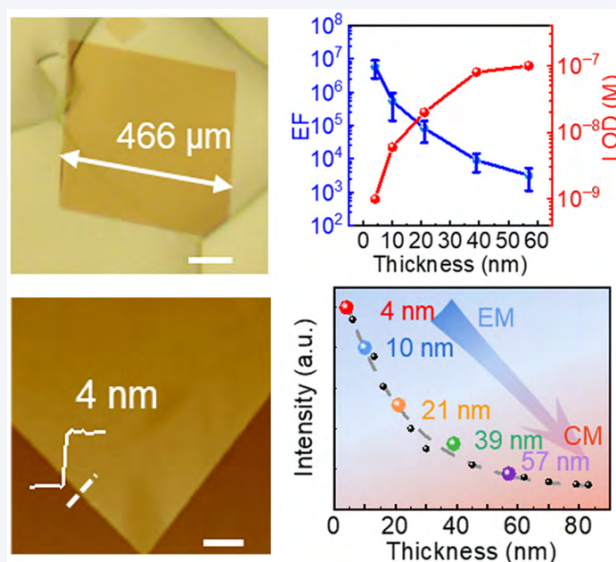
Cite this article: Nano Research, 2026, 19, 94908825. <https://doi.org/10.26599/NR.2026.94908825>

ABSTRACT: Metallic MoO₂ is promising to be one of noble-metal-comparable surface-enhanced Raman spectroscopy (SERS) substrate materials based on the strong electromagnetic mechanism (EM) enhancement. However, the SERS performance is still unable to meet the practical application requirements. Synthesizing large-scale two-dimensional (2D) metallic MoO₂ with controllable thickness, even at atomic level is an effective solution, but it has rarely been reported. The enhancement mechanism based on such kind of metallic metal oxide SERS substrates also lacks a more systematic study. Here, submillimeter-scale (~466 μm) atomic-thin (~4 nm) metallic MoO₂ was firstly synthesized by chemical vapor deposition (CVD). What's more, it shows high sensitivity as SERS substrates with a maximum enhancement factor up to 10⁷ and a limit of detection down to 10⁻⁹ M, which is at a high level among most metal oxide-based SERS substrates and even comparable to the values of noble metal substrates with "hot spots". It was also firstly and systematically found that both the EM (surface plasmon resonance (SPR) effect) and chemical mechanism (CM) (charge transfer process) enhancements exist simultaneously in such MoO₂ substrate. The key lies in the thickness of MoO₂ that determines the dominant enhancement mechanism. MoO₂ flakes not only possess noble-metal-comparable SERS performance, but also show potential in image security and information encryption.

KEYWORDS: metal oxides, molybdenum dioxide, chemical vapor deposition, surface-enhanced Raman spectroscopy, two-dimensional (2D) materials

1 Introduction

The surface-enhanced Raman spectroscopy (SERS) is a powerful analysis technique for sensitive structural detection with trace



concentration or even single-molecule levels, because it can significantly enhance Raman signals by several orders of magnitude than normal Raman [1–3]. SERS has already been widely used both in basic research fields and practical applications, such as biological sensing, catalysis chemistry, environmental monitoring, etc. [4–7]. There exist two accepted enhancement mechanisms in most reported studies, including electromagnetic mechanism (EM) and chemical mechanism (CM) [8]. EM as the primary one is induced by the local field magnification based on the surface plasmon resonance (SPR) of substrate materials [9]. Accordingly, noble metals with strong SPR effect such as Au and Ag, are used as

Received: March 11, 2026; Revised: May 7, 2026

Accepted: May 9, 2026

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traditional SERS substrates. When creating “hot spots” by fabricating rough surfaces or nanostructures of noble metals, an enhancement factor (EF) higher than 10^6 and a limit of detection (LOD) lower than 10^{-8} M can be obtained [10, 11]. However, such noble metal SERS substrates show poor biocompatibility and stability. The preparation of their nanostructures is also high-cost and the roughened surface morphology will inevitably produce non-uniform Raman signals [12].

Metal oxides are promising because of many excellent features, including low-cost, high chemical stability, and good biocompatibility. Recently, many kinds of metal oxide (e.g. TiO_2 , ZnO , and Cu_2O) nanostructures have been reported as SERS substrates [13–15]. Unfortunately, most of them show relatively low EF (10^2) and poor LOD (10^{-3} M), falling far short of the requirements of the trace detection. These semiconducting metal oxides lack strong SPR effect and Raman enhancement is derived from the charge transfer between the analytes and SERS substrates, regarded as the CM. The weak CM-based enhancement can be improved with EF in the range of (10^4 – 10^6) and LOD in the range of (10^{-4} – 10^{-9} M) by introducing high concentration of oxygen vacancy (such as TiO_{2-x} and $\text{W}_{18}\text{O}_{49}$) or preparing some special nanostructures (such as Cu_2O superstructure particle and TiO_2 microarray) [14, 16–18]. However, the thermal or chemical stability of these metal oxides are usually poor and their nanostructures will lead to non-uniform Raman signals. Some layered two-dimensional (2D) materials (e.g., graphene, MoS_2 , and WTe_2) have also been applied on SERS [19–23]. Although they have shown certain advantages in terms of stability and uniformity, their SERS performance is still low due to the relatively weak CM-based enhancement. Therefore, the discovery of a more potential SERS substrate material with strong SPR effect as well as low cost, high stability and good uniformity is still challenging [24].

Different from most reported CM-based semiconducting metal oxides and 2D materials, metallic molybdenum dioxide (MoO_2) has a strong SPR effect because of the existence of numerous free electrons. Combined with its low-cost and high-stability feature, it is promising to be one of noble-metal-comparable SERS substrate materials [25]. It has been reported that the highest EF was up to 10^6 with detection limits of 10^{-6} to 10^{-8} M, when using some MoO_2 -based nanostructures as SERS substrates [26]. However, the uniformity of SERS performance is still a problem due to their roughened surface morphologies. Preparing MoO_2 into large-scale 2D plates is likely an effective solution, but relevant works have rarely been reported at present. This is because MoO_2 as a kind of non-layered materials cannot be obtained by mechanically exfoliation from its bulk materials. Therefore, the large-scale preparation of these non-layered 2D materials with controllable thicknesses is inherently rather difficult [27]. The maximum grain size of currently reported 2D MoO_2 nanosheets by Wu et al. was only $\sim 5 \mu\text{m}$, with the minimum thickness of $\sim 7 \text{ nm}$ [28]. The corresponding maximum EF was also not high enough ($\sim 10^5$) to match the practical requirements of applications, which may be caused by the insufficient thickness because the enhancement performance increases as the thickness decreases. Synthesizing large-scale 2D MoO_2 with controllable thickness, even at atomic level is promising for developing new SERS substrates with noble-metal-comparable SERS performance. On the other hand, although the thickness-dependent SERS performance of metallic MoO_2 has been reported, a comprehensive and systematic study on the thickness-related enhancement mechanism is still lacking [25, 27, 28].

Herein, we firstly synthesize large-scale 2D metallic MoO_2 flakes

with controllable thicknesses by chemical vapor deposition (CVD). The maximum grain size is up to submillimeter level ($\sim 466 \mu\text{m}$) and the minimum thickness is at atomic level of $\sim 4 \text{ nm}$. What's more, these MoO_2 flakes show high sensitivity as SERS substrates with detected concentration down to 10^{-9} M and a maximum EF up to 10^7 , which is at a high level among most metal oxide-based SERS substrates and even comparable to the values of noble metal substrates with “hot spots”. Both the EM (SPR effect) and CM (charge transfer process) enhancements exist simultaneously in metallic 2D MoO_2 substrate, which is firstly and systematically reported. The key lies in its thickness that determines the dominant enhancement mechanism. The excellent SERS performance is realized by the thickness-dependent enhancement. In addition, MoO_2 flakes possess strong thermal and chemical stability after high-temperature (300°C) heating in air and corrosion resistance in strong acid or alkali. They are universal for many commonly used chemicals, and exhibit high uniformity and good reproducibility of Raman signals. These characteristics not only provide their noble-metal-comparable SERS performance, but also make them potential in image security and information encryption.

2 Result and discussion

2.1 CVD growth of submillimeter-scale atomic-thin metallic MoO_2

Large-scale 2D MoO_2 flakes with controllable thicknesses were grown on Au foils by CVD, as shown in Fig. 1(a). Here, Au foils act as not only the growth substrates but also the catalysts that promote the growth process. MoO_3 and Se powders were used as precursor and reductant, respectively. 2D MoO_2 flakes were synthesized at high temperature (900°C) in an Ar atmosphere. They are homogeneously distributed on the surface of Au and present a rhombic morphology with acute angle of $\sim 81^\circ$ (Fig. 1(b)). Details of preparation process were described in Experimental section and Fig. S1 in the Electronic Supplementary Material (ESM)). Au foils were reusable and barely affect the growth results as shown in Fig. S2 in the ESM. Interestingly, we found that the grain sizes and thicknesses of these flakes change with the amount of Se used gradually increasing from 30 to 110 mg. The grain size shows initially increases and then decreases, while the thickness presents the opposite tendency. Surprisingly, large-scale atomic-thin 2D MoO_2 with the maximum grain size of $\sim 466 \mu\text{m}$ and the minimum thickness of $\sim 4 \text{ nm}$ can be obtained with a moderate usage of Se powder (70 mg), as shown in Figs. 1(c) and 1(d). To further confirm the above results, we statistically analyzed the morphological changes including both grain sizes and thicknesses under different Se dosages. The data in Fig. 1(e) was collected by measuring 20 samples randomly selected in each figure in Fig. S3 in the ESM, which shows the same tendency. We have also made a comparison with the reported results about 2D metal oxides in Fig. 1(f). Obviously, our results show advantages both in terms of grain size and thickness control, which is very difficult and rarely reported for 2D non-layered metal oxides.

2.2 Structural characterization of 2D MoO_2

Raman spectroscopy and X-ray photoelectron spectroscopy (XPS) were preliminary used to characterize the structure information of MoO_2 flakes. As shown in Fig. 2(a), there are nine typical Raman peaks located at 124, 202, 228, 343, 362, 457, 495, 567 and 740 cm^{-1} ,

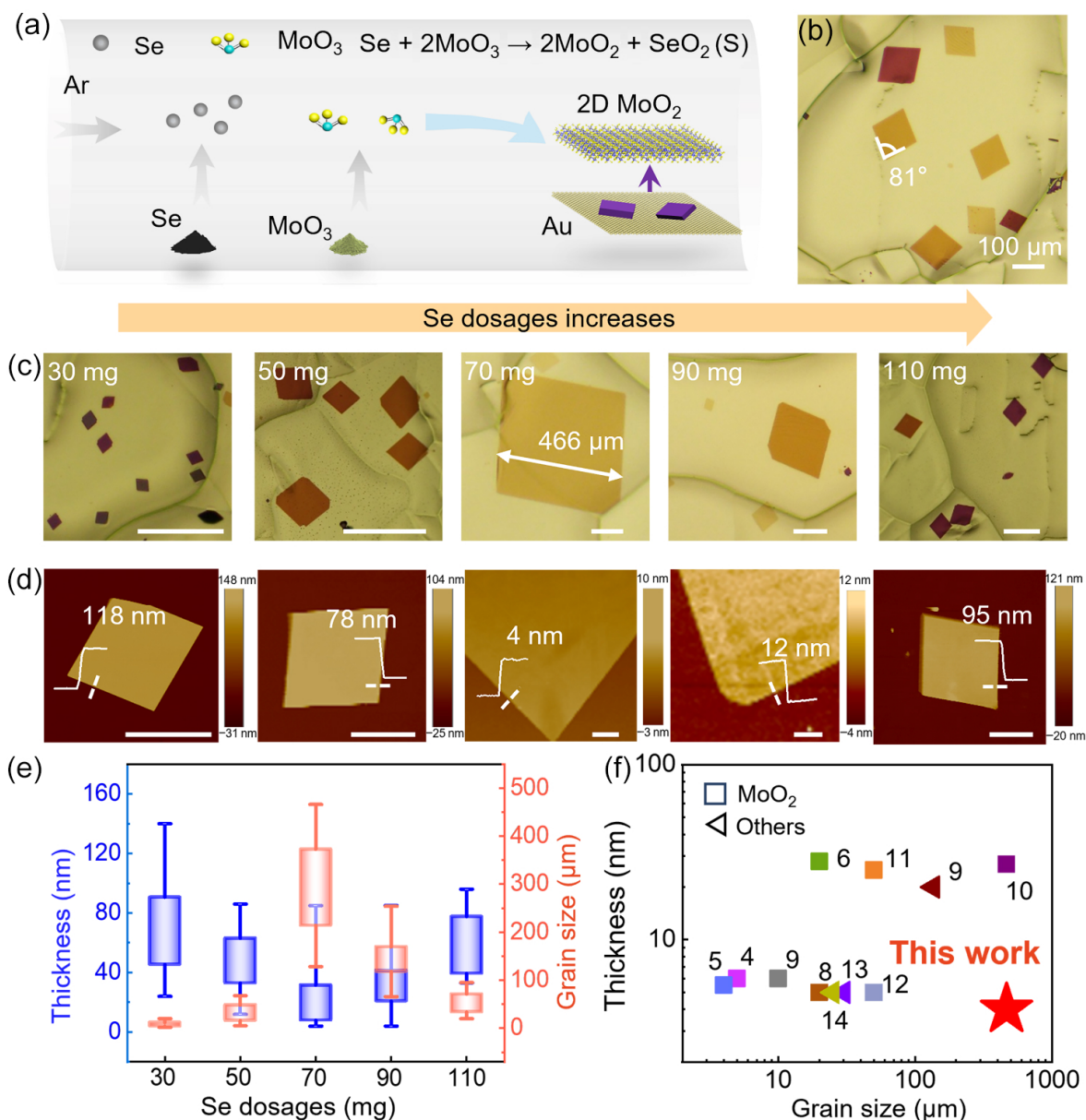


Figure 1 The synthesis of large-scale 2D MoO₂ flakes with controllable thicknesses. (a) The schematic diagram for CVD growth of 2D MoO₂. (b) Typical morphology of 2D MoO₂ flakes homogeneously distributed on Au surface. (c) Optical images of 2D MoO₂ flakes obtained with different Se dosages from 30 to 110 mg. The scale bar is 100 μm. (d) Corresponding AFM images measured from the representative MoO₂ flakes grown with different Se dosages. The scale bar is 10 μm. The AFM was implemented after the samples were transferred onto SiO₂/Si substrates by electrochemical bubbling transfer method (Fig. S1 in the ESM). (e) The statistical results of grain sizes and thicknesses, according to the randomly selected 20 samples in each optical image in Fig. S3 in the ESM. (f) The comparison of grain sizes and thicknesses of 2D metal oxides corresponding to the references in Table S1 in the ESM and this work.

respectively. The characteristic peaks at 567 and 740 cm⁻¹ can be attributed to bond vibration modes (Mo–O₁ and Mo–O₂) of MoO₂, while the other fingerprint peaks represent the phonon vibration modes of MoO₂. The valence states of Mo were also detected by XPS in Fig. 2(b). Here, the adventitious carbon 1s peak at 284.8 eV was used as a reference [29]. There exist three pairs of spin-orbit doublets (3d_{5/2} and 3d_{3/2}) in Mo 3d characteristic peaks, which are fitted at 229.0 and 232.5, 231.5 and 234.7, 233.1 and 236 eV, respectively. The former two pairs are attributed to the binding energies of Mo⁴⁺, while the last pair of doublets is derived from Mo⁶⁺, which may be attributed to slight oxidation on the surface, contamination, and the adsorption of some MoO₃ powders [28, 29]. The intensity and area of Mo⁴⁺ peaks are much more than that of

and Mo⁶⁺ peaks, indicating that molybdenum ion is mainly tetravalent as expected in MoO₂ stoichiometry. High-angle annular dark-field scanning transmission electron microscopy (HAADF-STEM) was also used to further confirm the microstructure of 2D MoO₂ flakes. Figures 2(c)–2(e) display the low-resolution STEM image of a rhombic MoO₂ flake and the corresponding EDS mappings of Mo and O elements. Figure 2(f) shows a representative HAADF-STEM of MoO₂, showing its perfect lattice structure and the spacing of (020) plane is 0.24 nm, which is consistent with the simulated atomic model. The Mo atoms are coordinated by six O atoms, forming two types of octahedrons. Such atomic structure possesses two kinds of Mo–Mo metallic bonds, which will lead to a large number of intrinsic free electrons. This is also the original

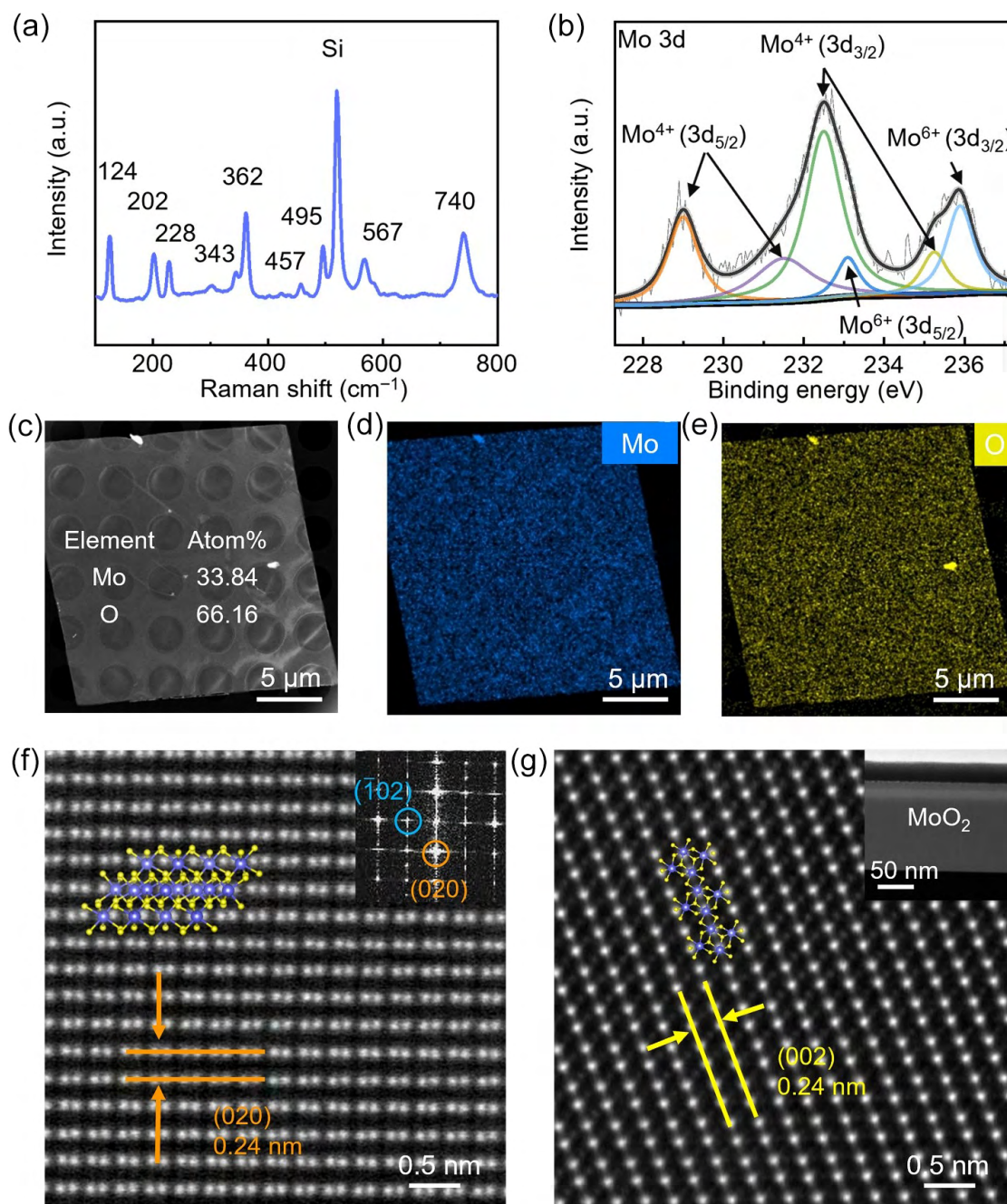


Figure 2 Structural characterization of 2D MoO₂ flakes. (a) Typical Raman spectrum of MoO₂ flakes on SiO₂/Si substrate. (b) XPS spectrum of molybdenum ion. (c) A low-resolution STEM image of a representative rhombic MoO₂ flake. Corresponding EDS mappings of (d) Mo and (e) O elements with their ratio of ~1:2 as shown in (c). (f) Representative HAADF-STEM image of MoO₂. The inset is the corresponding FFT pattern. (g) Cross-sectional HAADF-STEM image of MoO₂. The TEM image in the inset shows the morphology of the sample after cutting from the cross-sectional direction.

reason for the metallic feature and good SPR effect of 2D MoO₂ flakes, which will be discussed in the following text [30]. The inset is the corresponding fast Fourier transform (FFT) image, suggesting its single-crystal feature with high quality. We also observed its cross-section atomic arrangement by HAADF-STEM after cutting it through focused ion beam (FIB). The results in Fig. 2(g) further confirm the monoclinic structure of 2D MoO₂ flakes.

2.3 Noble-metal-comparable SERS performance

An ideal SERS substrate should exhibit a high EF, low LOD, high signal uniformity, excellent reproducibility, and long-term stability.

To evaluate the SERS performance of 2D MoO₂ flakes, methylene blue (MeB) was employed as the main probe molecule and 532 nm laser was served as the excitation source (Fig. S4 in the ESM). As shown in Fig. 3(a), no obvious Raman signal of MeB (10⁻⁶ M aqueous solution) appears on bare SiO₂/Si substrates, while Raman spectra obtained from MeB on 2D MoO₂ flakes display distinct characteristic peaks at 1391 cm⁻¹ (R₁) and 1625 cm⁻¹ (R₂) and MoO₂ itself did not exhibit similar Raman peaks on SiO₂/Si substrates. It indicates that the Raman signal enhancement of MeB is attributed to 2D MoO₂ flakes. Interestingly, we also found that such Raman enhancement effect has a strong dependence on the thickness of 2D

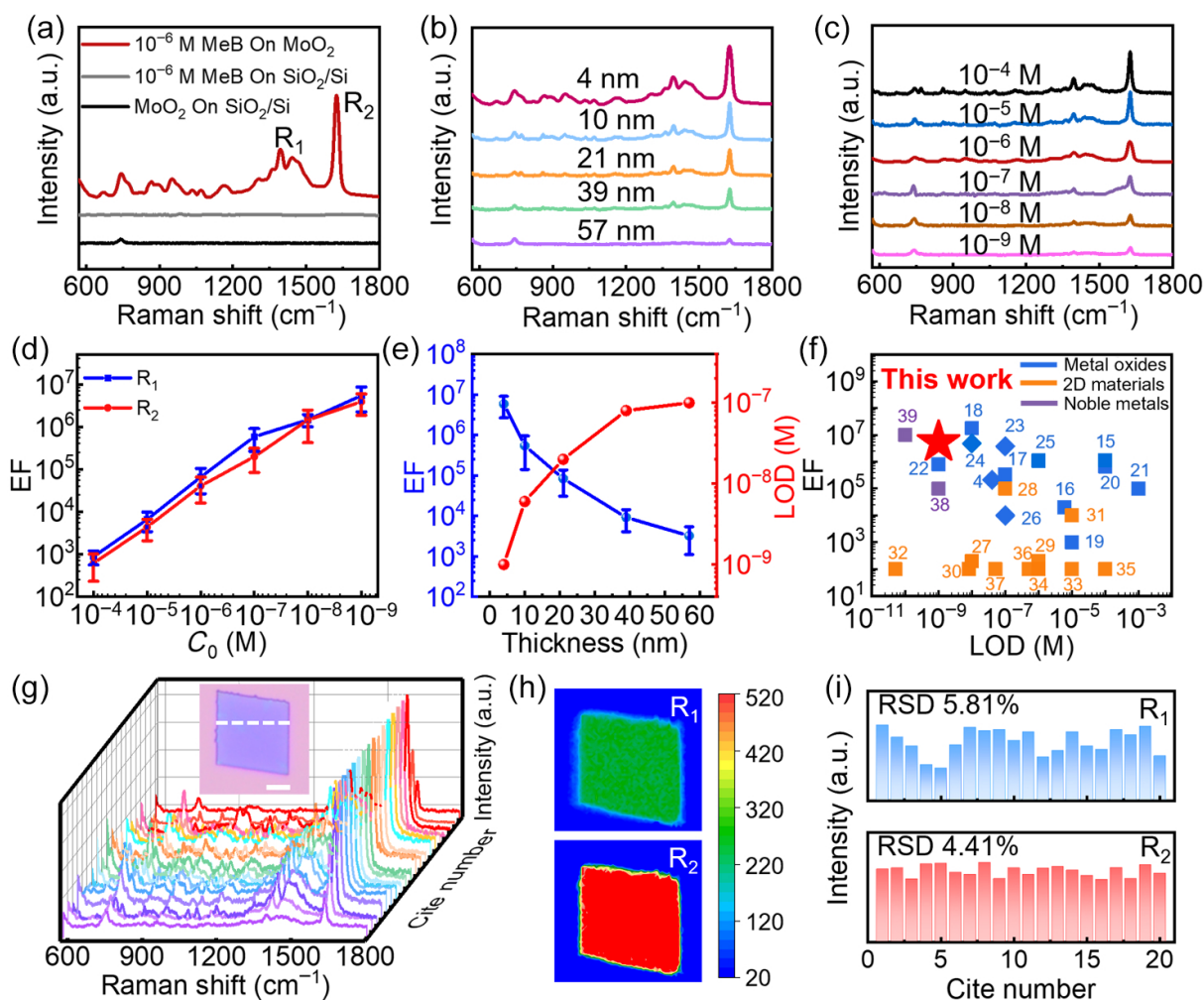


Figure 3 The noble-metal-comparable SERS performance of 2D MoO₂ flakes. (a) Raman spectra of 2D MoO₂ flake, 10⁻⁶ M MeB on SiO₂/Si substrate, and MeB on 2D MoO₂ flake (R₁ at 1391 cm⁻¹ and R₂ at 1625 cm⁻¹), respectively. (b) Raman enhancement variation with the changing of the thickness of 2D MoO₂ flakes. (c) Raman spectra of MeB solutions with different concentrations (from 10⁻⁴–10⁻⁹ M) on 4 nm-thick MoO₂. (d) The statistical results of corresponding enhancement factors of R₁ and R₂ peaks. (e) The enhancement effect changes of 2D MoO₂ with 5 different thicknesses on the R₂ peak of MeB. (f) The comparison of EF and LOD values obtained from 4 nm-thick MoO₂ with those from references in Table S2 in the ESM. (g) 20 Raman spectra of MeB molecules along the white dashed line in the inset which shows the optical image of 4 nm-thick MoO₂ on SiO₂/Si substrate. The scale bar is 5 μm. (h) Raman mappings of R₁ and R₂ peaks measured from 10⁻⁶ M MeB on the same MoO₂ flake in the inset of (g). (i) Raman intensities of R₁ and R₂ peaks collected from 20 randomly selected points on the MoO₂ flakes in (g).

MoO₂ flakes. For the same MeB aqueous solution, the enhancement of R₁ and R₂ peaks shows a stronger trend as the thickness of 2D MoO₂ flake decreases from 57 to 4 nm (Fig. 3(b) and Fig. S5 in the ESM). As shown in Fig. 3(c), we further observed the Raman signal enhancement phenomenon of MeB solutions with different concentrations (from 10⁻⁴ to 10⁻⁹ M) on 4 nm-thick MoO₂ and calculated the corresponding EFs of R₁ and R₂ peaks based on these results. To ensure the reliability of the data, we selected 20 points for each concentration of MeB solution for Raman testing (EF calculation and result statistics), as shown in Fig. 3(d). Surprisingly, EF obtained from 4 nm-thick MoO₂ can be as high as 5.4×10^6 , a value higher than that of most reported metal oxides and 2D materials, even comparable to that of noble metal SERS substrates with “hot spots”. Meanwhile, it can achieve trace substance detection, with its LOD as low as 10⁻⁹ M. Figure 3(e) shows the statistical analysis using the same calculation method to evaluate the EF and LOD of five different thicknesses of MoO₂ from Fig. 3(b), further confirming a strong thickness-dependent SERS performance. The thinner its thickness, the better its EF and

performance. At a thickness of 4 nm, which is the thinnest thickness reported in the current literature for large-scale 2D non-layered metal oxides materials, it exhibits the best Raman enhancement effect, as discussed in Fig. 3(d). A further comprehensive comparison of above results with the previously reported metal oxides, 2D materials and noble metal SERS substrates (Fig. 3(f) and Table S2 in the ESM) reveals that such atomic-thin metallic MoO₂ possesses high-level SERS performance and it is promising to become an ideal candidate comparable to noble metal SERS substrates.

In practical SERS applications, uniformity and reproducibility of Raman signals, as well as the stability and universality of substrate materials are also very important. Compared with noble metal SERS substrates, atomic-thin MoO₂ has a super smooth surface, which gives it a natural advantage in the uniformity of SERS signals [31, 32]. To prove this, a 4 nm-thick MoO₂ flake was used as the SERS substrate with MeB (10⁻⁶ M) as the probe molecule. 20 points along the white dashed line in the inset of Fig. 3(g) were chosen for SERS detection and all the Raman signals look highly similar. SERS

mappings were also performed in Fig. 3(h), both R_1 and R_2 Raman mappings show excellent uniformity within the entire MoO_2 flake. As shown in Fig. 3(i), we further calculated the relative standard deviations (RSDs) by randomly selecting 20 measurement points on the MoO_2 flake. The RSDs based on the intensities of corresponding Raman peaks R_1 and R_2 are only 5.81% and 4.41%, respectively. When the probe molecule was replaced with Rhodamine 6G (R6G), which exhibits a stronger fluorescence background than that of MeB, a similar conclusion was drawn in Fig. S6 in the ESM. All these results indicate that ultrathin 2D MoO_2 has high signal uniformity when used as a SERS substrate. In addition, it also features excellent reproducibility of SERS signals (Fig. S7(a) in the ESM) and universality for many commonly used chemicals (Fig. S8 in the ESM). 2D MoO_2 flakes exhibit strong thermal and chemical stability after high-temperature heating at 300 °C in air, as well as resistance to corrosion in strong acids or alkalis (Figs S9–S11 in the ESM).

2.4 High SERS performance realized by thickness-dependent enhancement mechanism

As shown in Figs. 4(a)–4(c), such monoclinic-phase MoO_2 presents a metallic character based on the theoretical calculations of

density functional theory (DFT), which is similar to previous results [25, 28]. The calculated electron localization function (ELF) in Fig. 4(c) reveals that there is a large amount of free electron gas around Mo^{4+} , which constitutes the non-polar Mo–Mo metal bond. Due to the presence of numerous free electrons, MoO_2 has a strong SPR effect, which is also an important reason for its excellent SERS performance as discussed in Fig. 3. It is worth noting that the free electron concentration of 2D MoO_2 is related to its thickness. As shown in Figs. 4(d) and 4(e), the current–voltage curves of MoO_2 with 5 different thicknesses were conducted. It was calculated that the electrical conductivity/resistivity gradually decreased/increased with the increasing of thicknesses from 4 to 57 nm. Ultraviolet–visible (UV–vis) absorption spectra in Fig. 4(f) show that 2D MoO_2 with 5 different thicknesses all have very distinct absorption peaks, confirming the strong SPR effect as reported [25, 26, 28]. We also found that the absorption peak gradually redshifts from 550 to 570 nm with the thickness increasing. This is because the plasma energy loss of 2D MoO_2 increases with the increase of thickness, resulting in a gradual weakening of its SPR effect [28, 33]. Therefore, due to the stronger SPR effect, 4 nm-thick atomic-thin MoO_2 exhibits superior SERS performance compared to samples with other thicknesses, as discussed in Fig. 3.

On the other hand, by comparing the absorption spectra for

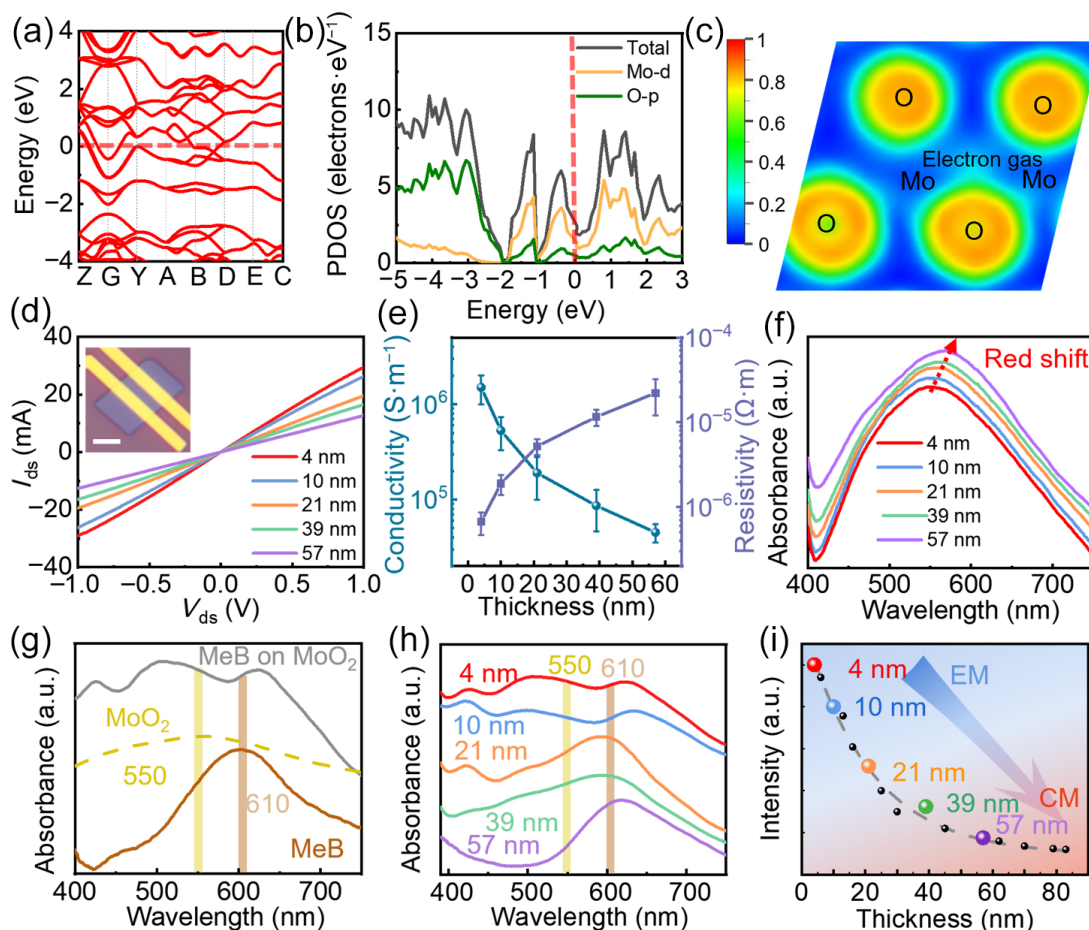


Figure 4 Thickness-dependent SPR effect and charge transfer of 2D MoO_2 . (a) The band structure of MoO_2 . (b) Electronic density of states for MoO_2 . The highest occupied states near the Fermi level of MoO_2 are mainly composed of Mo 3d orbitals. (c) The calculated ELF of MoO_2 . Charge localization gradually increases from green to orange regions. (d) A series of I – V curves obtained from MoO_2 flakes with 5 different thicknesses. The inset is a typical optical image of the device of MoO_2 , the scale bar is 10 μm . (e) The corresponding conductivity and resistivity calculated from (d). (f) UV–vis absorption spectra of MoO_2 with 5 different thicknesses. (g) The comparison of absorption spectra for MeB on MoO_2 and MeB. (h) UV–vis absorption of 10^{-6} M MeB on MoO_2 substrates with 5 different thicknesses. (i) The enhanced Raman signal intensity of 10^{-6} M MeB on MoO_2 with 15 different thicknesses from 4 to 83 nm, according to the Raman spectra in Fig. 3(b) and Fig. S13 in the ESM.

MeB on MoO₂ and MeB, we found that MeB will exhibit new absorption peaks and the shift of peak position with the existence of MoO₂ as substrates (Fig. 4(g)). This can be attributed to the charge transfer process caused by the interfacial interaction between MeB molecules and MoO₂ [25, 34]. The charge difference between them was also calculated by DFT to further confirm this point of view [35]. There exists a strong chemisorption between MeB molecules and MoO₂, with an adsorption energy of about −3.49 eV (Fig. S12 in the ESM). Meanwhile, an evident charge transfer process occurs at the interface that electrons are primarily transferred from Mo atoms to the regions around N atoms of MeB molecules, indicating the strong electronic coupling and significant interfacial interaction between MeB and MoO₂.

More importantly, such charge transfer process was also related to the thickness of 2D MoO₂, as observed in Fig. 4(h). With the thickness increasing, the charge transfer phenomenon becomes more obvious, which exactly shows the opposite trend of the thickness-related SPR effect as discussed in Figs. 4(d)–4(f). It is well known that SERS substrates with strong SPR effect usually exhibit a strong EM enhancement, while the charge transfer process usually dominates the relatively weak CM enhancement [8, 36–38]. Both the SPR effect and charge transfer process of 2D MoO₂ depend on its thickness and show opposite trends, resulting in its enhancement mechanism also having obvious thickness dependence, as shown in Fig. 4(i). This means that for 2D MoO₂ with different thicknesses, both EM and CM enhancement exist simultaneously, but which one plays a dominant role varies continuously with its thickness. With increasing the thickness of 2D MoO₂, its strong SPR effect weakens while the relatively weak charge transfer process intensifies. Therefore, thinner samples show strong EM enhancement, while relatively thicker samples show relatively weak CM enhancement. Accordingly, 4 nm-thick MoO₂ exhibits superior SERS performance compared to samples with other thicknesses. Such thickness-dependent enhancement mechanism was firstly comprehensively reported for metal oxide-based SERS substrates.

2.5 Applications in image security and information encryption

Atomic-thin MoO₂ not only has SERS performance comparable to that of noble metals with “hot spots”, but also features precise signal recognition and strong anti-interference ability. It is expected to be applied in high-tech fields such as layer information encryption and image anti-counterfeiting. For instance, after the same MoO₂ sample was successively immersed in three different aqueous solutions of R6G, MV, and MeB (see Experimental), the Raman signal was tested. As shown in Fig. 5(a), the Raman characteristic peaks of each organic compound could be fully displayed without interfering with each other. Then, we formed a 5 × 5 rectangular array with 25 ultra-thin MoO₂ flakes (each square in the matrix is 25 μm × 25 μm). The array was patterned by deposited R6G, MV, and MeB aqueous solutions, respectively forming the corresponding N, E, and U graphs as shown in Fig. 5(b). When the Raman characteristic peak of a specific organic compound is selected as the test object, the matrix will display the corresponding character graphic, thereby achieving a simple information encryption function. For specific examples, when the Raman peaks marked by the red, blue, and yellow dotted areas in Fig. 5(a) are tested respectively, the matrix area will correspondingly show the N, E, and U graphs pre-deposited by R6G, MV, and MeB. When cracking encrypted information, we can obtain the marked graphics one by one by

providing the characteristic peaks, sequences and occurrence frequencies of individual organic substances, and then display the encrypted information. As shown in Fig. 5(c), when the decrypted numbers are 612, 912, 770, and 985, we can obtain the image information of NENU.

In addition, after calibrating several different components of the image with different organic substances and selecting specific Raman peaks for detection, it is possible to selectively display part or the entire image information to achieve the purpose of image anti-counterfeiting. As shown in Fig. S14(a) in the ESM, we constructed an array of panda images using several ultrathin MoO₂ flakes, and labeled the panda eyes, panda contours and bamboo parts in the images with R6G, MV and MeB, respectively (Fig. 5(d)). When detecting the Raman signal mapping of the entire image array, choosing an appropriate measurement range can display partial images of a single organic label (Figs. S14(b)–S14(d) in the ESM), or partial combined images of more than two organic labels. For example, when the test range is 1150–1200 cm^{−1} (the area marked by the purple dotted line in Fig. 5(a)) and 1600–1669 cm^{−1}, the patterns shown in Figs. 5(e) and 5(f) will be displayed respectively.

3 Conclusion

In summary, large-scale (~ 466 μm) atomic-thin (~ 4 nm) metallic MoO₂ was firstly synthesized by Se-assisted CVD. It shows high SERS sensitivity with detected concentration down to 10^{−9} M and a maximum EF up to 10⁷, which is at a high level among most metal oxide-based SERS substrates, and even comparable to the values of noble metal substrates with “hot spots”. Both the SPR effect and charge transfer process of 2D MoO₂ depend on its thickness and show opposite trends, resulting in its enhancement mechanism also having obvious thickness dependence. It means that both EM and CM enhancement exist simultaneously, but which one plays a dominant role varies continuously with thicknesses. Therefore, 4 nm-thick MoO₂ exhibits superior SERS performance compared to samples with other thicknesses due to the relatively stronger EM enhancement induced by SPR effect. In addition, it also features excellent reproducibility of SERS signals, good stability, as well as universality for a variety of detected substances. Large-scale 2D metallic MoO₂ is not only an ideal substrate for SERS, but also potential in image security and information encryption. This work offers important insights for the synthesis of non-layered metal oxides and other 2D materials, which can help develop the SERS performance and applications with 2D metal oxide-based substrate materials.

4 Experimental

4.1 Growth 2D MoO₂ on Au by CVD

2D MoO₂ flakes were synthesized by CVD in a tube furnace. Au foil (99.99 wt.%, 100 μm-thick, 1 cm × 1 cm, Beijing Kairi Material Technology Co., LTD.) was ultrasonically cleaned with acetone, isopropyl alcohol and ethanol for 20 min, and then annealed at 1050 °C in air for more than 10 h. Firstly, the annealed Au foil was placed in the center of the quartz tube, and 100 mg MoO₃ powder (99.999 wt.%, Adamas) was placed 3 cm upstream of the Au foil. 70 mg Se powder (99.99 wt.%, Aladdin) was heated separately and placed upstream of outside the high temperature zone. The distance between selenium powder and Au foil was about 18.5 cm. The

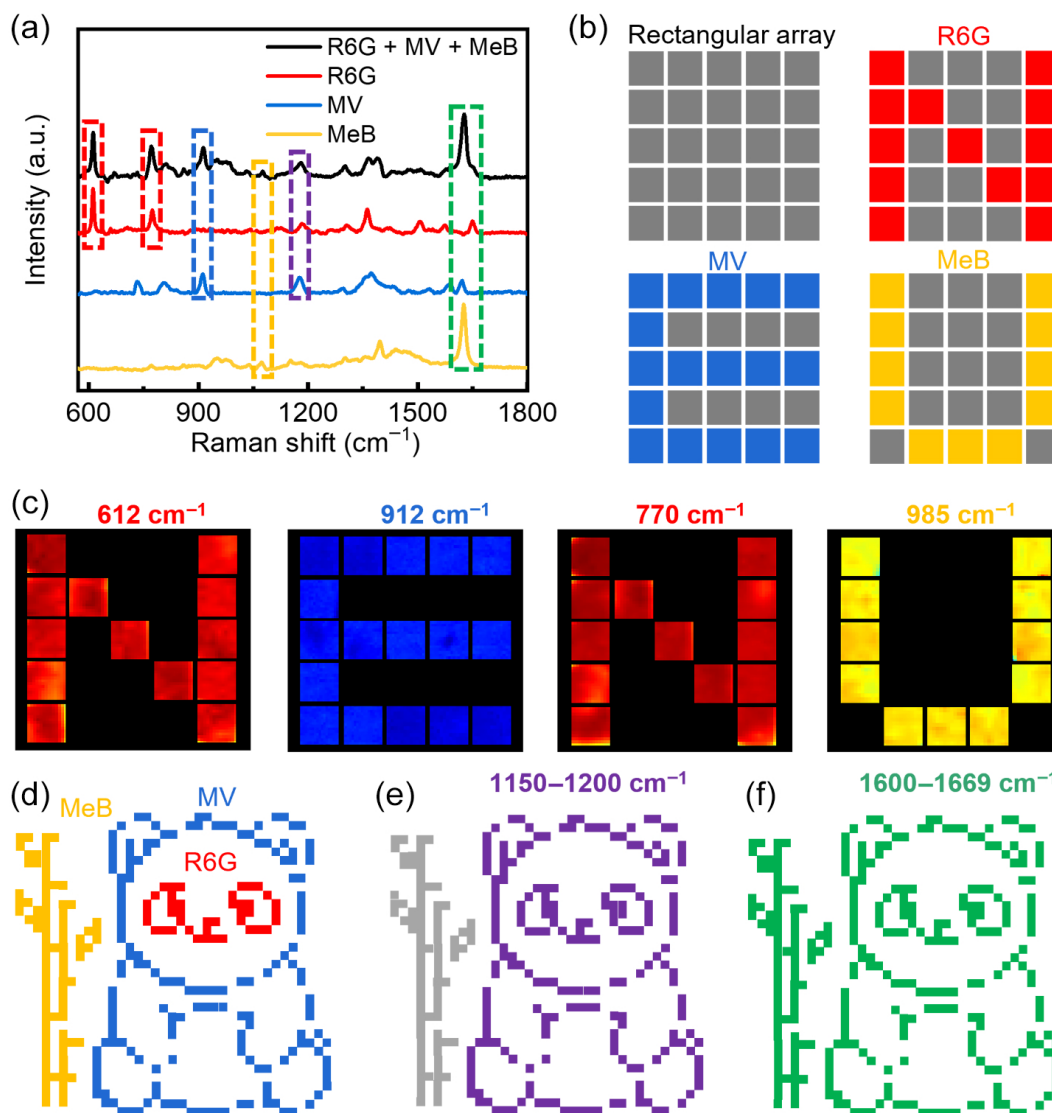


Figure 5 2D MoO₂ substrates for graphic information encryption and image security. (a) Raman peaks marked by the red, blue, and yellow dotted lines show the characteristic peaks of R6G, MV, and MeB on MoO₂ flakes, respectively. (b) A 5 × 5 rectangular array based on 25 ultra-thin MoO₂ flakes. The thickness range of the MoO₂ flakes is 4–10 nm and the size of each square in the array is 25 μm. (c) The obtained image information of NENU by selecting Raman peaks at 612, 912, 770, and 985 cm⁻¹, respectively. (d)–(f) An array of panda images using several ultrathin MoO₂ flakes. Panda eyes, panda contours, and bamboo parts were labeled with R6G, MV, and MeB, respectively. Partial or complete patterns can be displayed by selecting an appropriate measurement range.

furnace was heated from room temperature to 750 °C in 30 min and 900 °C in 10 min. When the furnace was heated to 900 °C, MoO₂ was grown on substrate after growth process lasted for 6 min. 100 standard cubic centimeter per minute (sccm) argon gas was introduced into the whole process. The sample was cooled rapidly to room temperature.

4.2 Characterization

The morphology of MoO₂ was characterized by optical microscopy (Olympus BX51 microscope). An atomic force microscope (AFM, Bruker Dimension Icon) system was used to determine the thickness of MoO₂. XPS (ESCALAB 250) was used to characterize the chemical composition of MoO₂. The atomic structure of MoO₂ was carried out by TEM on an FEI Titan Themis Cube with an X-FEG electron gun and a DCOR aberration corrector operating at 100 kV. UV–vis absorption spectroscopy was used by a commercial integrated platform including xenon lamp (300–1100 nm).

4.3 Devices fabrication and electrical property measurements

MoO₂ was transferred onto Si substrates with a 280 nm-thick SiO₂ layer. Then, the 10 nm Ti/50 nm Au layer electrodes were deposited by electron beam evaporation. An agilent semiconductor parameter analyzer (4155C Semiconductor Parameter Analyser) was used to measure the electrical properties at room temperature.

4.4 Raman test

Raman spectra were obtained with a Raman spectrometer (JY HR-800 LabRAM) by using a 532 nm semiconductor laser (output power: 50 mW, spot size: 1 μm) as the excitation source. R6G, MeB, MB, RhB, and MV dissolved in deionized water were employed to be the probe molecules. The stock solutions were prepared at a concentration of 10⁻⁴ M and then diluted to 10⁻⁵, 10⁻⁶, 10⁻⁷, 10⁻⁸, and 10⁻⁹ M. In the section of LOD, signal uniformity and reproducibility

of SERS, 2D MoO₂ substrates were soaked in a series of concentrations of aqueous solution for 30 min, and dried in a clean N₂ atmosphere. In the section of EF calculation and graphic information encryption and image security, several microliters of aqueous solution of organic molecules were dripped onto the substrate surface and dried naturally in the air before conducting the Raman test. Then, the same type of confocal Raman spectrometer was used to collect the Raman spectrum, using a 532 nm laser with 5 mW power, 50 × objective lens, and a single acquisition time of 10 s. The acquisition time of Raman mapping was 1 s. By fitting a polynomial, the background of all Raman spectra was extracted and removed.

4.5 DFT calculations

The DFT calculations of monoclinic MoO₂ were performed using the generalized gradient approximation (GGA)/Perdew–Burke–Ernzerhof (PBE) as the exchange–correlation functional in the Vienna *ab initio* simulation package (VASP) and DFT-D3 for van der Waals (vdW) correction. Starting from the experimental crystal structure of monoclinic MoO₂ (space group: *P*₂₁/*c*), the cell parameters and atomic positions were further relaxed until the total Hellmann–Feynman forces on each atom were < 0.01 eV·Å^{−1}. The uniform Brillouin zone grids of 5 × 6 × 5 K point for geometry optimization were used and the plane-wave basis set cutoff of the wavefunctions was set at 500 eV.

The charge density difference between MeB and MoO₂ was calculated using the VASP. The electron–ion interactions were described by projector augmented wave (PAW) method. The exchange–correlation interactions were conducted with the PBE functional within the GGA. DFT-D3 correction was employed for long-range van der Waals interactions. To account for the solvation effect in aqueous environments, the implicit solvation model implemented in VASPsol was used. The plane-wave cutoff energy was 520 eV for both structural optimizations and self-consistent calculations. The convergence criteria for electronic and ionic relaxations were 1 × 10^{−5} eV per atom and 0.05 eV·Å^{−1}, respectively.

Electronic Supplementary Material: Supplementary material (details of CVD preparation, Raman detection, EF calculation, SERS performance, and DFT analysis) is available in the online version of this article at <https://doi.org/10.26599/NR.2026.94908825>.

Data availability

All data needed to support the conclusions in the paper are presented in the manuscript and the Electronic Supplementary Material. Additional data related to this paper may be requested from the corresponding author upon request.

Acknowledgements

This work was supported by the National Key Research and Development Program of China (No. 2023YFB3610200), the Program of Natural Science Foundation of China (Nos. 52002056, 12274065, 62275045, and 62574038), the Fundamental Research Funds for the Central Universities (No. 2412025PD013), the Science and Technology Development Plan Project of Jilin Province (No. 20240601049RC), the Foundation of Jilin Educational Committee of China (No. JJKH20221151KJ), and the Natural Science Foundation of Jilin Province (No. 20240101318JC). The

authors sincerely acknowledge Dr. H. Zhu and Dr. G. Wang for providing technology supporting on characterization of the samples.

Declaration of competing interest

All the contributing authors declare no conflict of interests in this work.

Author contribution statement

Y. Z. B.: Data curation, project administration, validation, writing manuscript, experimental design. J. M. C., M. F. D. and D. M. C.: Data curation. J. Z.: validation. X. X.: Project administration, funding acquisition. W. X., W. Z. L., P. L., J. G. M., H. Y. X., and Y. C. L.: Project administration, funding acquisition. All the authors have approved the final manuscript.

Use of AI statement

None.

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